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11064 U.S. PTO

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Docket No.: M-11021 US

November 1, 2001

Box Patent Application
Commissioner For Patents
Washington, D. C. 20231

Enclosed herewith for filing is a patent application, as follows:

Inventors: Entley, William R.; Langan, John G; Hall, Randy;
Title: In Situ Plasma Process To Remove Fluorine Residues From The Interior Surfaces Of A CVD Reactor

- X Return Receipt Postcard
- X This Transmittal Letter (in duplicate)
- 15 pages Specification(not including claims)
- 3 pages Claims
- 1 page Abstract
- 4 Sheets of Drawings
- 3 pages Declaration For Patent Application and Power of Attorney
- 1 page NonPublication Request
- 1 pages Recordation Form Cover Sheet (in duplicate)
- 2 pages Assignment
- 1 page Information Disclosure Statement
- 1 page PTO Form 1449 citing 7 references
- ☒ Copies of 7 Cited References submitted

CLAIMS AS FILED

For	Number Filed		Number Extra		Rate		Basic Fee
Total Claims	21	-20 =	1	x	\$18.00 =	\$	740.00 18.00
Independent Claims	1	-3 =	0	x	\$84.00 =	\$	0.00
<input type="checkbox"/>	Fee of _____ for the first filing of one or more multiple dependent claims per application						\$
<input type="checkbox"/>	Fee for Request for Extension of Time						\$

Please make the following charges to Deposit Account 19-2386:

- ☒ Total fee for filing the patent application in the amount of \$ 758.00
- ☒ The Commissioner is hereby authorized to charge any additional fees which may be required, or credit any overpayment to Deposit Account 19-2386.

EXPRESS MAIL LABEL NO:

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Respectfully submitted,

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11/01/01
10/003908
JC580 U.S. PTO

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MODIFIED PTO/SB/35 (11-00)

REQUEST AND CERTIFICATION UNDER 35 U.S.C. 122(b)(2)(B)(i)	Inventors	Entley, William R.; Langan, John G.; Hall, Randy
	Title	In Situ Plasma Process To Remove Fluorine Residues From The Interior Surfaces Of A CVD Reactor
	Atty Docket Number	M-11021 US

I hereby certify that the invention disclosed in the attached application **has not and will not be** the subject of an application filed in another country, or under a multilateral agreement, that requires publication at eighteen months after filing. I hereby request that the attached application not be published under 35 U.S.C. 122(b).

November 1, 2001
Date


David E. Steuber
Attorney for Applicants
Reg. No.: 25,557

This request must be signed in compliance with 37 CFR 1.33(b) and submitted with the application **upon filing**.

Applicant may rescind this nonpublication request at any time. If applicant rescinds a request that an application not be published under 35 U.S.C. 122(b), the application will be scheduled for publication at eighteen months from the earliest claimed filing date for which a benefit is claimed.

If applicant subsequently files an application directed to the invention disclosed in the attached application in another country, or under a multilateral international agreement, that requires publication of applications eighteen months after filing, the applicant **must** notify the United States Patent and Trademark Office of such filing within forty-five (45) days after the date of the filing of such foreign or international application. **Failure to do so will result in abandonment of this application (35 U.S.C. 122(b)(2)(B)(iii)).**

7 CFR 1.213(a) provides for a request that an application not be published under 35 U.S.C. 122(b). Confidentiality is governed by 35 U.S.C. 122 and 37 CFR 1.14. SEND TO: Commissioner for Patents, Washington, DC 20231.

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